

# Antiferromagnetic quantum anomalous Hall effect under spin flips and flops

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The interplay between nontrivial band topology and layered antiferromagnetism in  $\text{MnBi}_2\text{Te}_4$  has opened a new avenue for exploring topological phases of matter<sup>1–4</sup>. The quantum anomalous Hall effect<sup>5</sup> and axion insulator state<sup>6</sup> have been observed in odd and even number layers of  $\text{MnBi}_2\text{Te}_4$ , and the quantum metric nonlinear Hall effect<sup>7,8</sup> has been shown to exist in this topological antiferromagnet. The rich and complex antiferromagnetic spin dynamics in  $\text{MnBi}_2\text{Te}_4$  is expected to generate new quantum anomalous Hall phenomena that are absent in conventional ferromagnetic topological insulators, but experimental observations are still unknown. Here we fabricate a device of 7-septuple-layer  $\text{MnBi}_2\text{Te}_4$  covered with an  $\text{AlO}_x$  capping layer, which enables the investigation of antiferromagnetic quantum anomalous Hall effect over wide parameter spaces. By tuning the gate voltage and perpendicular magnetic field, we uncover a cascade of quantum phase transitions that can be attributed to the influence of complex spin configurations on edge state transport. Furthermore, we find that an in-plane magnetic field enhances both the coercive field and the exchange gap of the surface state, in contrast to that in the ferromagnetic quantum anomalous Hall state. Combined with numerical simulations, we propose that these peculiar features arise from the spin flip and flop transitions that are inherent to a van der Waals antiferromagnet. The versatile tunability of the quantum anomalous Hall effect in  $\text{MnBi}_2\text{Te}_4$  paves the way for potential applications in topological antiferromagnetic spintronics<sup>9,10</sup>.

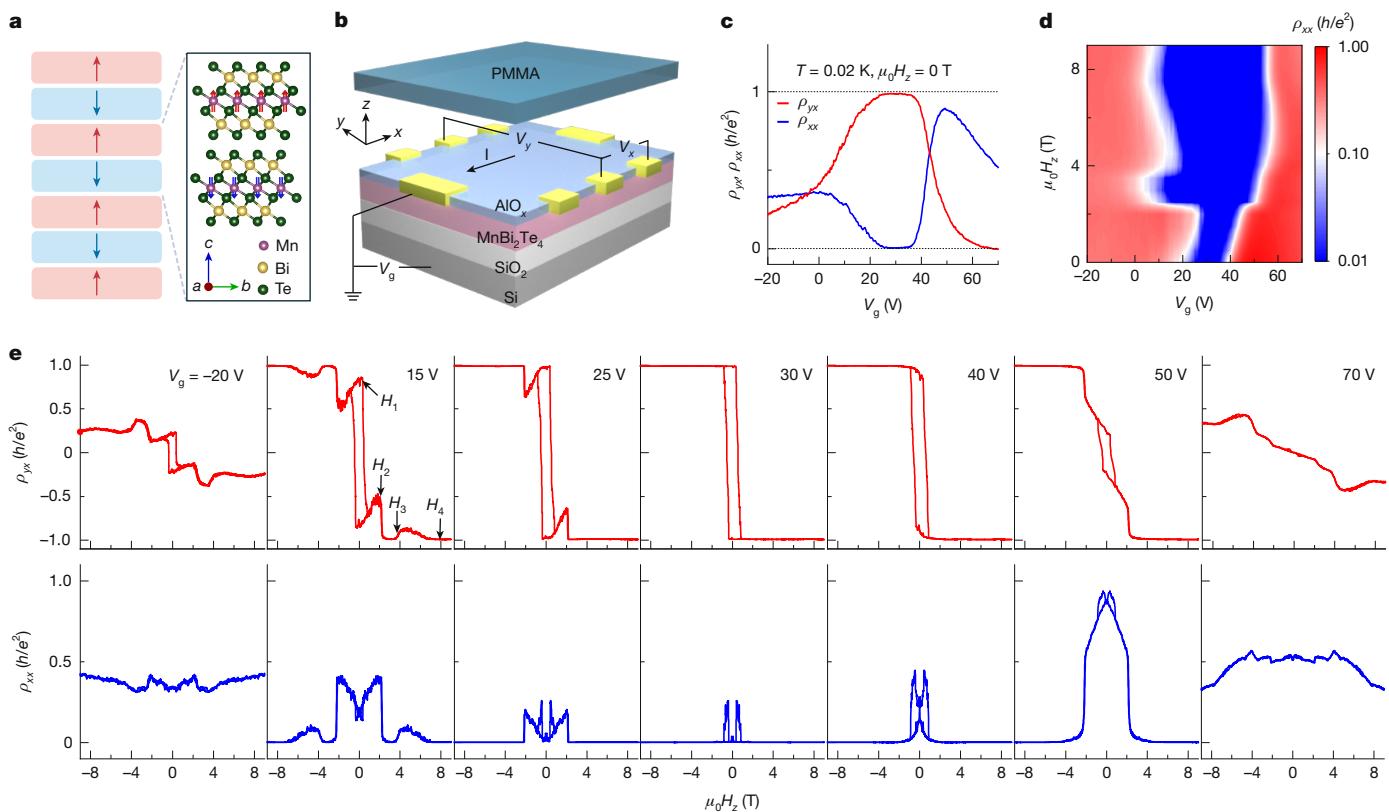
The quantum anomalous Hall (QAH) effect realizes one-dimensional dissipationless chiral edge state transport in the absence of external magnetic field<sup>11</sup>. Over the past decade, the pursuit of new materials exhibiting the QAH effect with new types of quantization has been a rapidly developing field<sup>5,11–19</sup>. Among the various systems explored, only  $\text{MnBi}_2\text{Te}_4$  hosts the QAH effect in the presence of bulk antiferromagnetic (AFM) order, thus can be dubbed the AFM QAH state. As shown in Fig. 1a, the Mn moments in each septuple layer (SL) exhibit intralayer ferromagnetic order, but AFM order between neighbouring SLs<sup>1–3,6,20–24</sup>. As proposed theoretically, different spin stacking sequences of the SLs and various metamagnetic phases will lead to fundamentally different bulk band topology and edge state conduction<sup>25–28</sup>. Recently, even–odd layer-dependent magnetism and the long-sought surface spin flop (SSF) transition have been observed in  $\text{MnBi}_2\text{Te}_4$  (refs. 29–31), which triggered the search for new QAH behaviour modulated by spin configurational variations. However, there has been limited experimental progress along this direction, mainly owing to the technical challenges in obtaining high-quality devices with zero-field quantization<sup>5</sup>. It has been shown that the  $\text{MnBi}_2\text{Te}_4$  crystals are prone to various types of defect<sup>32–39</sup>, and the

nano-fabrication process for transport device may introduce further complications<sup>40</sup>.

In this work, we design a new device architecture based on 7-SL  $\text{MnBi}_2\text{Te}_4$ , in which markedly improved quantum transport performance can be achieved. The  $\text{MnBi}_2\text{Te}_4$  single crystal is grown by solid-state reaction, and its high Néel temperature  $T_N \approx 26$  K indicates high crystalline quality (see Supplementary Figs. 1–3 for the calibrations of bulk crystal). We notice that in most odd-number-SL  $\text{MnBi}_2\text{Te}_4$  devices exhibiting a large anomalous Hall effect (AHE), one surface of the thin film is in contact with  $\text{AlO}_x$ , either as the exfoliation agent<sup>5,41</sup> or as epitaxial substrate<sup>42,43</sup>. This suggests that  $\text{AlO}_x$  may play an important part in enhancing the AHE in this system, most likely by stabilizing the surface out-of-plane magnetic order. The enhancement of perpendicular magnetic anisotropy (PMA) has been frequently observed in spintronic material systems, such as Pt/Co/ $\text{AlO}_x$  (refs. 44–47). Our first-principles calculations also demonstrate an enhancement of surface PMA for  $\text{MnBi}_2\text{Te}_4$  covered with  $\text{AlO}_x$ , primarily because of the hole doping and strong spin–orbit coupling of Te atoms (Supplementary Information section B). We implement this idea by depositing an  $\text{AlO}_x$  capping layer on the exfoliated  $\text{MnBi}_2\text{Te}_4$  flake before performing

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**Fig. 1 | Crystal structure, device configuration and  $V_g$ -dependent transport of 7-SL  $\text{MnBi}_2\text{Te}_4$ .** **a**, Schematic crystal structure of  $\text{MnBi}_2\text{Te}_4$ . The red and blue arrows indicate the direction of magnetic moments of Mn ions in different SLs. **b**, Schematic transport configuration of a 7-SL  $\text{MnBi}_2\text{Te}_4$  flake on a  $\text{SiO}_2/\text{Si}$  substrate. The top surface of  $\text{MnBi}_2\text{Te}_4$  is covered with a 3-nm  $\text{AlO}_x$  capping

layer. **c**,  $V_g$ -dependent  $\rho_{yx}$  and  $\rho_{xx}$  at  $\mu_0H_z = 0 \text{ T}$  and  $T = 0.02 \text{ K}$ . The QAH effect appears at the CNP around  $V_g = 30 \text{ V}$ . **d**, Colour map of  $\rho_{xx}$  as a function of  $V_g$  and  $H_z$ . The blue region represents the area of the QAH state. **e**,  $H_z$  dependence of  $\rho_{xx}$  and  $\rho_{yx}$  at various  $V_g$ s at  $T = 0.02 \text{ K}$ . The arrows in the  $V_g = 15 \text{ V}$  panel indicate the four characteristic field scales of the cascaded quantum phase transitions.

spin-coating of polymethyl methacrylate (PMMA), as schematically shown in Fig. 1b (see Methods for details). The  $\text{AlO}_x$  layer also protects against the environmental contamination and damage from the fabrication process<sup>40</sup>, which is detrimental to the QAH effect. The other side of the flake directly lies on the  $\text{SiO}_2/\text{Si}$  substrate, which also serves as a bottom-gate dielectric.

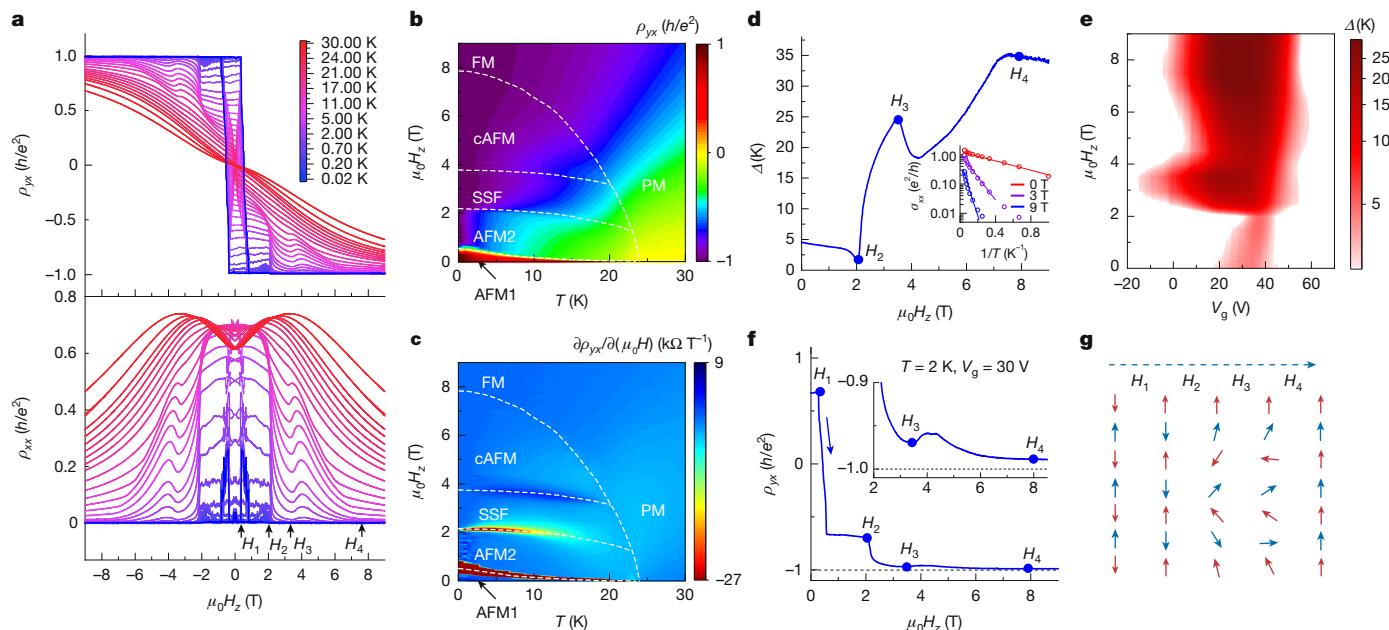
## Cascade of quantum phase transitions in AFM QAH effect

Our device architecture enables the investigation of the AFM QAH effect over a wide range of control parameters, including gate voltage ( $V_g$ ), temperature ( $T$ ), perpendicular and in-plane magnetic fields. Figure 1c presents the  $V_g$ -dependent Hall resistivity ( $\rho_{yx}$ ) and longitudinal resistivity ( $\rho_{xx}$ ) measured at  $T = 0.02 \text{ K}$  in zero perpendicular magnetic field  $\mu_0H_z = 0 \text{ T}$ . The quantized  $\rho_{yx}$  and vanishing  $\rho_{xx}$  at the charge neutrality point (CNP) around  $V_g = 30 \text{ V}$  demonstrate the dissipationless nature of the chiral edge state in the QAH phase. To map out the full phase diagram, we sweep  $V_g$  at different fixed  $H_z$  values. Figure 1d shows the colour map of  $\rho_{xx}$  as a function of  $V_g$  and  $H_z$ , in which the blue region with small  $\rho_{xx}$  represents the QAH state (see Extended Data Fig. 1 for the  $\rho_{yx}$  map and transport results for different  $H_z$ ). The QAH region expands suddenly as  $\mu_0H_z$  increases to around 2.2 T, especially for the hole-doped side ( $V_g < 30 \text{ V}$ ) that was unexplored before<sup>5</sup>. The QAH region then shrinks abruptly near 3.8 T, and after that broadens gradually with increasing  $H_z$ . Compared with that in the ferromagnetic topological insulator systems<sup>11,48–50</sup>, the AFM QAH state here demonstrates a much richer response to variations in  $V_g$  and  $H_z$ .

To illustrate the quantum transport more clearly, in Fig. 1e we show the  $H_z$ -dependent  $\rho_{yx}$  and  $\rho_{xx}$  loops at  $T = 0.02 \text{ K}$  for representative  $V_g$ s.

At  $V_g = 30 \text{ V}$ , the sample exhibits the anticipated QAH effect with  $\rho_{yx}$  being nearly quantized at  $0.981h/e^2$ , and  $\rho_{xx}$  dropped to  $0.011h/e^2$  at  $\mu_0H_z = 0 \text{ T}$ . At  $\mu_0H_1 \approx 0.5 \text{ T}$ , there is a sharp plateau transition corresponding to the sign reversal of the Chern number from  $C = +1$  to  $-1$ . Above that,  $\rho_{yx}$  remains at the quantized plateau because for a narrow range of  $V_g \approx 30 \text{ V}$  the QAH state persists over the entire  $H_z$  regime, which can be visualized as a vertical linecut in Fig. 1d. When  $V_g$  deviates from the CNP, we first observe a linear behaviour of  $\rho_{yx}$  at low  $H_z$ , indicating that hole- ( $V_g \leq 25 \text{ V}$ ) and electron-type ( $V_g \geq 40 \text{ V}$ ) carriers begin to contribute to the ordinary Hall effect. With varied  $V_g$  and  $H_z$ , a cascade of quantum phase transitions characterized by the deviation and recovery of  $\rho_{yx}$  quantization start to emerge, especially in the hole-doped regime that was unexplored before<sup>5</sup>. As indicated by the arrows in the  $V_g = 15 \text{ V}$  panel, at  $\mu_0H_2 \approx 2.2 \text{ T}$  the  $\rho_{yx}$  shows a sudden jump and returns to the  $-h/e^2$  plateau, meanwhile  $\rho_{xx}$  drops from a finite value to nearly zero. The quantized state is maintained until  $\mu_0H_3 \approx 3.8 \text{ T}$ , above which it is suppressed into a broad region with pronounced dissipation. When the magnetic field exceeds  $\mu_0H_4 \approx 7.8 \text{ T}$ , the quantized  $\rho_{yx}$  plateau and vanishing  $\rho_{xx}$  are restored and strengthened.

We then study the  $T$  evolution of the  $\rho_{yx}$  and  $\rho_{xx}$  loops at  $V_g = 30 \text{ V}$ , as shown in Fig. 2a (see Extended Data Fig. 2 for separately displayed curves). In contrast to the quantized  $\rho_{yx}$  plateau persisting over the entire  $H_z$  range at  $T = 0.02 \text{ K}$ , the high- $T$  curves exhibit much more complex variations that resonate with the cascaded  $V_g$  evolution at the ground state. Most of the curves exhibit four characteristic  $H_z$  scales, namely, the  $\rho_{yx}$  sign reversal at  $H_1$ , the sudden increase in  $\rho_{yx}$  at  $H_2$ , the weakening of  $\rho_{yx}$  at  $H_3$ , and the recovery of  $\rho_{yx}$  plateau above  $H_4$ . To directly visualize the  $T$ -dependent phase transitions, we plot the variation of  $\rho_{yx}$  and its derivative versus  $H_z$  in the  $T$ - $H_z$  plane, as shown by the coloured maps in Fig. 2b,c. Here the four white dashed lines represent



**Fig. 2 |  $T$  dependence of transport properties at  $V_g = 30 \text{ V}$  and thermally activated gap fitting at varied  $\mu_0 H_z$ .** **a**,  $H_z$ -dependent  $\rho_{yx}$  and  $\rho_{xx}$  loops at selected temperatures at  $V_g = 30 \text{ V}$ . **b,c**, Colour maps of  $\rho_{yx}$  and  $\partial \rho_{yx} / \partial H_z$ . The phase diagram is separated into the AFM1, AFM2, SSF, cAFM, ferromagnetic (FM) and paramagnetic (PM) regions by four characteristic field scales ( $H_1, H_2, H_3, H_4$ ) marked by white dashed lines. **d**, The thermal activation gap size  $\Delta$  as a

function of  $H_z$ . The inset shows the Arrhenius plots of  $\sigma_{xx}$  at  $\mu_0 H_z = 0, 3$ , and  $9 \text{ T}$ . **e**, Colour map of  $\Delta$  as a function of  $H_z$  and  $V_g$ . **f**, Evolution of  $\rho_{yx}$  with  $\mu_0 H_z$  at  $T = 2 \text{ K}$ , which shows a one-to-one correspondence between the  $\rho_{yx}$  transitions and changes of  $\Delta$ . **g**, Schematic magnetic configurations for the 7-SL device for varied  $H_z$ .

the characteristic  $H_z$  scales that separate the phase diagram into several distinct regions, and the nature of each phase will be discussed later.

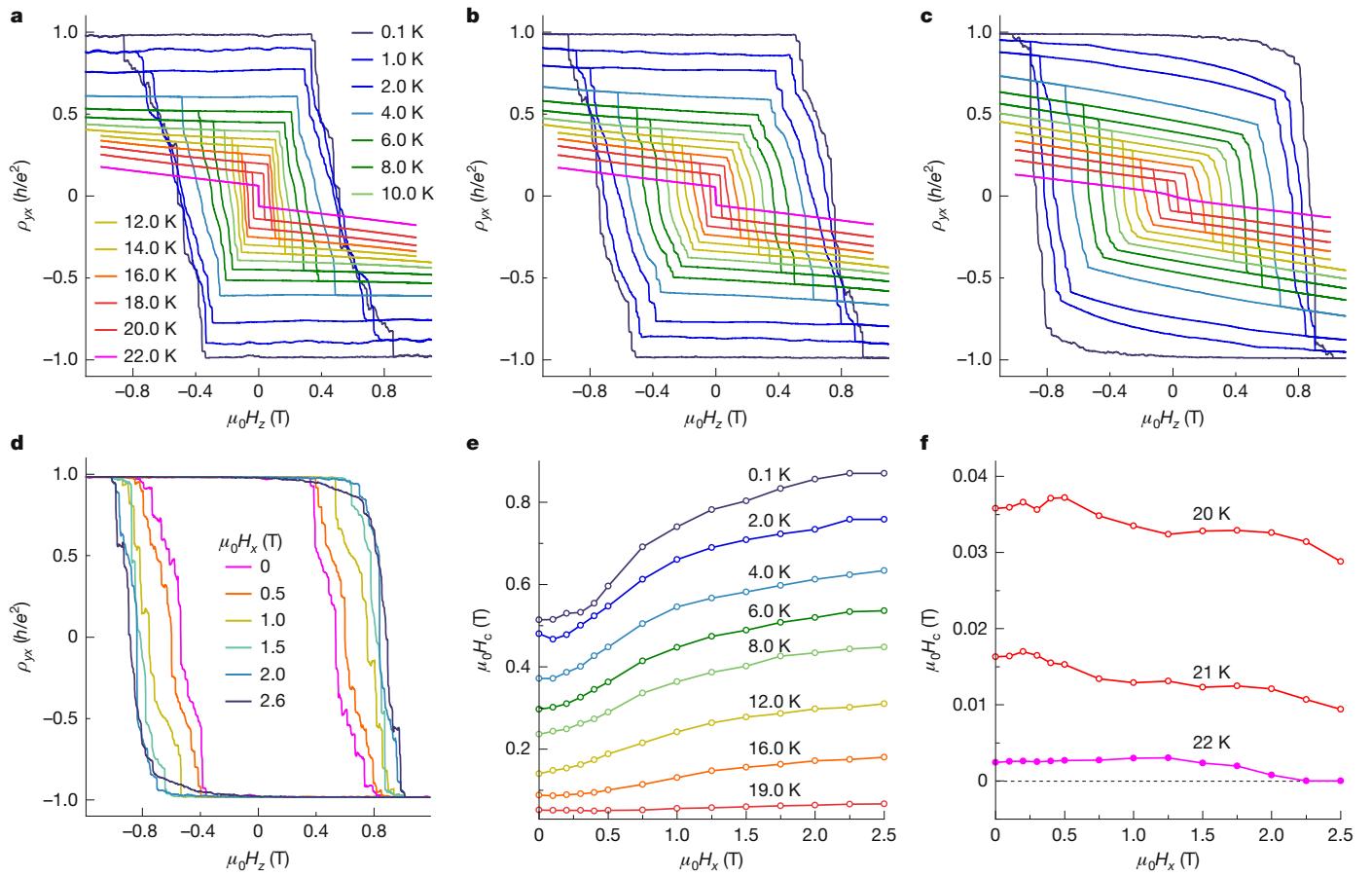
### Spin flips and flops in the van der Waals AFM state

To quantitatively characterize the robustness of each quantized state, we perform the Arrhenius fitting on the longitudinal conductivity  $\sigma_{xx}$  versus  $T$  to extract the thermal activation gap size  $\Delta$  around the Dirac point of the surface state. The complete colour maps of  $\sigma_{xx}$  as a function of  $T$  and  $V_g$  at various  $\mu_0 H_z$  are presented in Extended Data Fig. 3. As shown in the Fig. 2d (inset),  $\log(\sigma_{xx})$  exhibits a linear dependence on  $1/T$ , indicating a thermal activation behaviour  $\sigma_{xx} \propto \exp(-\Delta/2k_B T)$ . Figure 2d shows the evolution of  $\Delta$  as a function of  $H_z$  at  $V_g = 30 \text{ V}$ . The most dramatic feature is the abrupt jump of  $\Delta$  at  $\mu_0 H_z \approx 2.2 \text{ T}$ , after which  $\Delta/k_B$  increases from about 4 K to near 25 K. Above  $\mu_0 H_3 \approx 3.8 \text{ T}$ , it begins to decrease, reaches a minimum and increases again up to around 35 K at  $\mu_0 H_4 \approx 7.8 \text{ T}$ . Figure 2f and its inset show the  $H_z$  dependence of  $\rho_{yx}$  at  $T = 2 \text{ K}$ , which shows a one-to-one correspondence between the  $\rho_{yx}$  transitions and  $\Delta$  variations. Figure 2e shows the mapping of  $\Delta$  with  $H_z$  under different  $V_g$ s, which exhibits a similar pattern as the  $\rho_{xx}$  map in Fig. 1d.

The  $H_z$ -dependent gap size helps to identify the corresponding magnetic order of each state. By performing a simulation based on the modified AFM spin chain model<sup>29,31,51–53</sup>, in conjunction with previous results, we derive the magnetic configurations schematically shown in Fig. 2g (see Supplementary Fig. 9 for details). The evolution of magnetic configuration in  $H_z$  plays an important part in the electronic band structure, as well as the quantized transport. First-principles calculation for the band structure of these noncollinear metamagnetic states is a formidable task, but we can gain more insights about the relationship between spin configuration and electronic structure utilizing the coupled Dirac cone model for possible collinear ground states<sup>26</sup>. As shown in Supplementary Information section D, we demonstrate that the  $\Delta$  value is determined mainly by the perpendicular magnetization of the surface and subsurface SLs. Therefore, the measured gap size

provides an important clue about the spin orientations of the surface and subsurface layers, which overcomes the limitation of previous magnetic measurements that detect only the overall magnetization<sup>29–31,54</sup>. Below we describe the magnetic order and corresponding gap size for each phase.

The transition at  $H_1$  is because of the spin flip from the  $\downarrow \uparrow \downarrow \uparrow \downarrow \uparrow$  (AFM1) state to the  $\uparrow \downarrow \uparrow \downarrow \uparrow \uparrow$  (AFM2) state, where  $\uparrow$  and  $\downarrow$  represent the magnetization of each SL. This spin flip leads to the switch of Chern number between  $\pm 1$  but  $\Delta$  remains intact. Above  $H_4$ , the magnetic moments in all SLs are polarized into the ferromagnetic state, leading to a robust Chern insulator phase with large  $\Delta$ . The slow suppression of  $\Delta$  at even higher  $H_z$  can be attributed to the opposite sign of the internal exchange field in  $\text{MnBi}_2\text{Te}_4$  to the external  $H_z$ , as shown in previous experiments<sup>55</sup>. The  $\mu_0 H_3 \approx 3.8 \text{ T}$  field scale coincides with the bulk spin flop transition that has been demonstrated by polar reflective magnetic circular dichroism (RMCD)<sup>29,31</sup>, after which all SLs enter the canted AFM (cAFM) state that can exhibit the QAH effect in thin flakes<sup>22</sup>. During this process, the z-component of bulk magnetization increases with  $H_z$  but is reduced at the bottom SL, leading to a slightly decreased gap size<sup>29</sup>. This is consistent with the trend shown in Supplementary Information section D that the perpendicular magnetization near the surface plays a much more important part in determining  $\Delta$  than the bulk magnetization. The  $\mu_0 H_2 \approx 2.2 \text{ T}$  transition is the most puzzling one, which causes a marked increase in  $\Delta$ . We note that this field scale is very close to the SSF transition in 6-SL  $\text{MnBi}_2\text{Te}_4$  with bare top surface<sup>29,31,54</sup>, which should be absent in odd-SL devices. In our 7-SL device, the strong bonding of the top SL with the  $\text{AlO}_x$  capping layer may induce much stronger PMA and much weaker AFM coupling with the subsurface layer<sup>53</sup>. At  $H_2$ , the bottom 6-SL block undergoes a SSF transition, similar to that revealed by RMCD measurement and theoretical calculation<sup>29</sup>. After that, the subsurface SL is flopped to nearly parallel to the top SL, and the bottom SL keeps an out-of-plane magnetization. This magnetic configuration is highly beneficial for the QAH effect because of the enhancement of near-surface magnetization<sup>26,27</sup>, leading to the significant increase of  $\Delta$ .



**Fig. 3 | Enhancement of the hysteresis by an in-plane magnetic field.**

**a–c**, Evolution of  $H_z$ -dependent  $\rho_{yx}$  loops with  $T$  at in-plane magnetic field  $\mu_0 H_x = 0$  T (**a**), 1 T (**b**) and 2.5 T (**c**). In each panel, the loop shrinks with increasing  $T$ , but overall they become wider with increasing  $H_x$ . **d**, The  $\mu_0 H_z$ -dependent

$\rho_{yx}$  loops at  $T = 0.02$  K for varied  $\mu_0 H_x$ , directly showing the enhancement of hysteresis by in-plane magnetic field. **e,f**, The coercive field  $H_c$  as a function of  $H_x$  for various  $T$ s. It increases with  $H_x$  up to 19 K (**e**), but above that the trend reverses (**f**).

### Anomalous influence of the in-plane magnetic field

Now the spin configuration of each phase is clarified, we use another tuning parameter, the in-plane magnetic field  $H_x$ , to manipulate the magnetic order and quantum transport phenomena. Figure 3–c shows the  $T$  evolution of  $\rho_{yx}$  versus  $H_z$  loops measured at  $V_g = 30$  V under selected  $H_x$  values. In each panel, the hysteresis loops shrink with increasing  $T$  (the complete dataset is shown in Extended Data Figs. 4 and 5), just as expected. However, for the same  $T$  in the low  $T$  regime, the hysteresis loops expand with increasing  $H_x$ , indicating the enhancement of coercivity. This trend can be directly illustrated by comparing the hysteresis loops in varied  $H_x$  at  $T = 0.02$  K, as shown in Fig. 3d. The enhancement of hysteresis becomes weaker and exhibits an opposite trend at higher  $T$ , and the coercive loop at 22 K is completely suppressed by a sufficiently large  $H_x$ . In Fig. 3e,f, we plot the variation of coercive field  $H_c$ , defined by the field scale when  $\rho_{yx} = 0$ , as a function of  $H_x$  at different  $T$ s, which demonstrates the two opposite trends in different  $T$  regions.

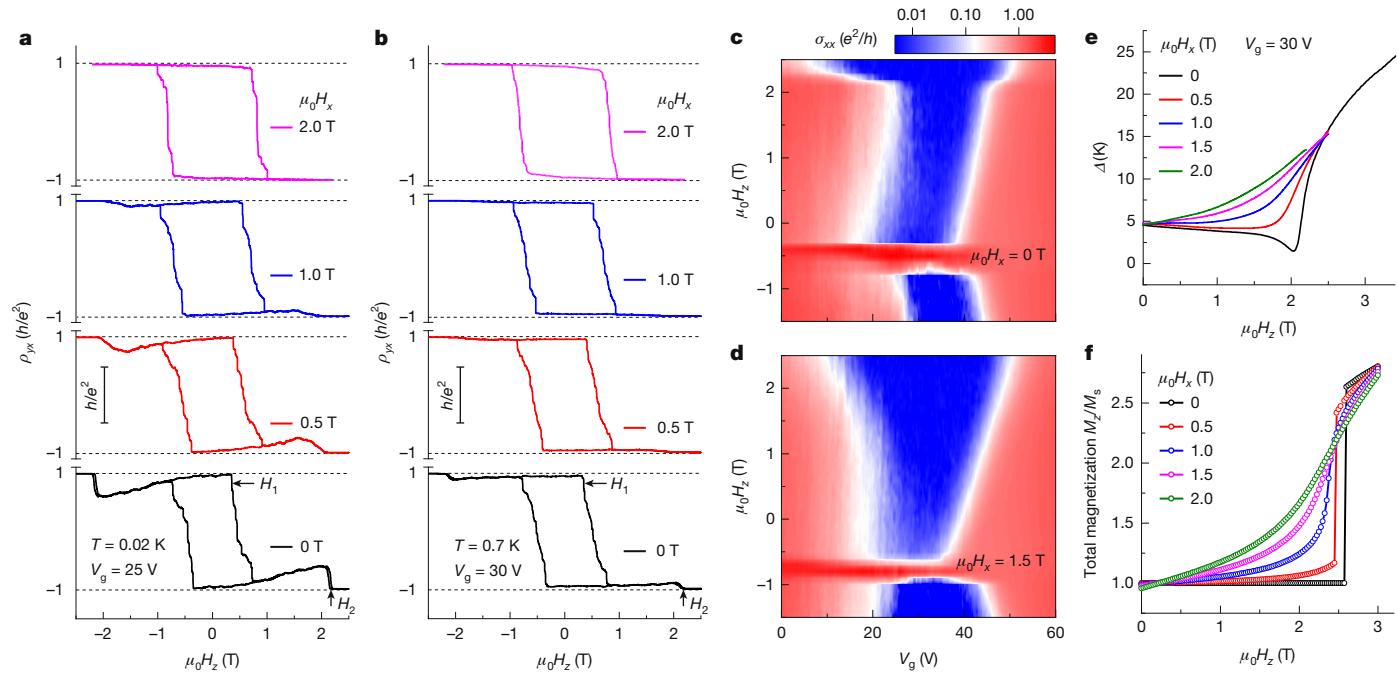
Apart from the enhancement of hysteresis, the in-plane field also strengthens the AFM QAH effect. Figure 4a,b shows the influence of  $H_x$  on the  $\rho_{yx}$  compared with  $H_z$  loops for two regimes in the phase diagram: the hole-doped region ( $V_g = 25$  V) at  $T = 0.02$  K and the CNP region ( $V_g = 30$  V) at  $T = 0.7$  K. In the absence of  $H_x$ , both regimes have weakened QAH effect with nonquantized  $\rho_{yx}$  between  $H_1$  and  $H_2$ . As  $H_x$  increases, in both cases  $\rho_{yx}$  is enhanced to form a well-developed quantum plateau and the transition near  $H_2$  becomes smoother. Figure 4c,d shows the phase diagrams at  $T = 0.02$  K constructed by plotting  $\sigma_{xx}$  in the  $V_g$  and  $H_z$  plane for  $\mu_0 H_x = 0$  and 1.5 T, respectively (see Extended Data Fig. 6

for the complete data of  $\sigma_{xx}$  colour map for varied  $H_x$ ). Notably, the application of  $H_x$  enlarges the blue area with dissipationless chiral edge state transport. Figure 4e presents the evolution of  $\Delta$  in different  $\mu_0 H_x$  values extracted from the temperature dependences (see Extended Data Fig. 7 for the raw data), which demonstrates the increase of  $\Delta$  and the smoothing of  $\mu_0 H_x \approx 2.2$  T transition induced by  $H_x$ .

The enhancement of coercivity and QAH effect by an in-plane magnetic field contrasts with that for magnetically doped topological insulators<sup>56</sup>. As shown recently in Cr doped  $(\text{Bi},\text{Sb})_2\text{Te}_3$  thin films, an in-plane field significantly decreases the  $H_c$  and suppresses the zero field  $\rho_{yx}$ . Both trends can be explained by the Stoner–Wohlfarth model for coherent rotation<sup>57,58</sup>, in which the in-plane field tilts the perpendicular magnetization and reduces the switching barrier. The highly unusual influence of the in-plane magnetic field on the AFM QAH effect in  $\text{MnBi}_2\text{Te}_4$  is against our intuition and must be related to its unique spin dynamics.

### Discussion

To explain the enhancement of QAH effect by the in-plane magnetic field, we still resort to the simulation based on the modified AFM spin chain model<sup>29,31,51–53</sup>. The simulation renders a change of spin configuration that can well account for the anomalous behaviour, as shown in Supplementary Fig. 8. The key factors are the  $\text{AlO}_x$  capping layer and the van der Waals AFM order that are unique to the 7-SL  $\text{MnBi}_2\text{Te}_4$  device studied here. The strong PMA of the top SL and the reduced AFM coupling with the subsurface layer ensures that in the presence of



**Fig. 4 | The enhancement of QAH effect by an in-plane magnetic field.** The  $\mu_0 H_z$ -dependent  $\rho_{yx}$  at  $V_g = 25$  V and  $T = 0.02$  K (**a**),  $V_g = 30$  V and  $T = 0.7$  K (**b**) in different  $H_x$ . In both cases, the QAH state between  $H_1$  and  $H_2$  is enhanced by the in-plane magnetic field. **c,d**, The colour map of  $\sigma_{xx}$  as a function of  $H_z$  and  $V_g$  with  $\mu_0 H_x = 0$  and  $1.5$  T, respectively, at  $T = 0.02$  K. The blue region characteristic of

the QAH state is widened by  $H_x$ . **e**, The evolution of extracted  $\Delta$  with  $H_z$  in different  $H_x$ . **f**, The simulated total magnetization along the  $z$ -axis under different  $H_x$  based on a modified AFM spin chain model. It shows similar behaviour as  $\Delta$  in **e**, indicating the enhancement of QAH effect by in-plane magnetic field.

in-plane magnetic field, the enhancement of  $z$ -component magnetization due to the down-moment rotation exceeds the reduction of the  $z$ -component due to the up-moment tilting. As shown in Fig. 4f, the total magnetization along the  $z$ -axis is enhanced by  $H_x$ , especially for SLs near the surface, which facilitates the gap opening at the Dirac point<sup>26,27</sup>. The in-plane magnetic field thus promotes an earlier transition into the SSF state, as demonstrated in both the experiment (Fig. 4e) and the simulation (Fig. 4f), leading to a larger energy gap hence better QAH state.

The increase of  $H_c$  by in-plane magnetic field turns out to be a much more complicated problem and cannot be explained simply by the AFM spin chain model or micromagnetic simulations. There are two key differences between the AFM QAH state here and the ferromagnetic QAH state in magnetically doped topological insulators. First, the local moments in  $\text{MnBi}_2\text{Te}_4$  form a regular lattice rather than random spatial distribution. Second, the interlayer exchange is AFM rather than ferromagnetic. The uncompensated spins of the 7-SL  $\text{MnBi}_2\text{Te}_4$  leads to a net magnetization along the  $z$ -axis, and the AFM1 to AFM2 transition at  $H_c$  corresponds to the coherent flips of all magnetic layers simultaneously because they collectively form the quantum ground state. Therefore, a much more sophisticated model might be needed to describe this phase transition and the enhancement of coercivity by in-plane magnetic field. It has been shown that a transverse field can enhance domain pinning and harden the magnet through site-random fields in a disordered Ising spin chain with ferromagnetic dipole interaction<sup>59,60</sup>. It is interesting to see if this mechanism also applies to the van der Waals AFM order in  $\text{MnBi}_2\text{Te}_4$ . At higher  $T$  close to  $T_N$ , the weakened AFM order and increased thermal fluctuations may drive the system into a classical regime described by the Stoner–Wohlfarth model, in which the in-plane field softens the hysteresis.

The 7-SL  $\text{MnBi}_2\text{Te}_4$  device with an  $\text{AlO}_x$  capping layer exhibits a cascade of quantum phase transitions induced by the influence of spin flips and flops on the topological transport properties that are unique to the van der Waals layered AFM order. The close correlation between magnetism and band topology also enables us to probe the magnetic

order through quantum transport measurements. We find that an in-plane magnetic field enhances both the hysteresis and the energy gap on the topological surface state, in contrast to that in ferromagnetic QAH systems. This powerful in situ knob is crucial for exploring new topological phenomena based on the AFM QAH effect and the application of  $\text{MnBi}_2\text{Te}_4$  in topological AFM spintronics<sup>9,10</sup>.

## Online content

Any methods, additional references, Nature Portfolio reporting summaries, source data, extended data, supplementary information, acknowledgements, peer review information; details of author contributions and competing interests; and statements of data and code availability are available at <https://doi.org/10.1038/s41586-025-08860-z>.

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# Article

## Methods

### Crystal growth

The  $\text{MnBi}_2\text{Te}_4$  single crystal was grown using the solid-state reaction method. Initially, Mn lump (99.95%, Alfa Aesar) and Te lump (99.999% Alfa Aesar) were mixed in a 1:1 ratio according to the chemical composition. The mixture was ground into powder in an agate mortar, placed into a quartz ampoule and vacuum sealed. The ampoule was slowly heated to 900 °C and maintained at this temperature for 72 h, resulting in the formation of MnTe. Subsequently, the quartz ampoule was removed from the box furnace at 900 °C and quenched in water, yielding MnTe crystals.

Simultaneously, Bi lump (99.999%, 3A) and Te lump (99.999%, Alfa Aesar) were mixed in a 2:3 ratio, ground into powder, placed into a quartz ampoule and vacuum sealed. The ampoule was slowly heated to 800 °C and maintained at this temperature for 6 h, allowing for the uniform mixing of elemental Bi and Te. The temperature was then gradually decreased to 582 °C at a rate of 3 °C min<sup>-1</sup> and maintained for 4 days. Then, the quartz ampoule was removed from the box furnace and quenched in water, resulting in  $\text{Bi}_2\text{Te}_3$  crystals.

Subsequently, MnTe,  $\text{Bi}_2\text{Te}_3$  and elemental Te were mixed in a 1:1:0.2 molar ratio. The mixture was ground into powder in an agate mortar, placed into a quartz ampoule and vacuum sealed. The ampoule was slowly heated to 900 °C at a rate of 3 °C min<sup>-1</sup> and maintained at this temperature for 1 h, allowing for the uniform melting and mixing of the raw materials. Subsequently, the sample was cooled at a rate of 3 °C min<sup>-1</sup> to 700 °C, held at this temperature for 1 h. The temperature was then gradually decreased to 585 °C at a rate of 0.5 °C min<sup>-1</sup> and maintained for annealing for 12 days. After the annealing process, the quartz ampoule was quenched in water to avoid phase impurities. Millimetre-sized  $\text{MnBi}_2\text{Te}_4$  crystals were obtained after crushing the ingot.

### Device fabrication

Thin flakes of  $\text{MnBi}_2\text{Te}_4$  were exfoliated using the Scotch tape method onto an Si substrate with 285 nm  $\text{SiO}_2$  and pre-cleaned in air plasma for 3 min at approximately 125 Pa pressure. The exfoliation process involved heating at 60 °C for 3 min. The sample thickness was determined by the optical contrast of the photo. Subsequently, a 3-nm layer of aluminium was deposited on the exfoliated samples in a thermal evaporator. Following the deposition, oxygen was introduced into the deposition chamber to maintain a pressure of  $2 \times 10^{-2}$  Pa for 5 min to oxidize aluminium. Then, the surrounding thick layer regions of the flake were removed by a needle. After that, we performed spin-coating of a layer of PMMA resist onto the sample, followed by baking at 60 °C for 7 min. Electrodes were patterned using a standard electron-beam lithography, followed by etching the oxidized aluminium on the top of the sample in an Ar ion milling machine. Metal electrodes (Cr/Au, 3/50 nm) were then deposited using a thermal evaporator connected to a glove box. Finally, the sample was immersed in acetone for the removal of photoresist films. All fabrication processes were conducted in an Ar-filled glove box with  $\text{O}_2$  and  $\text{H}_2\text{O}$  levels maintained below 0.1 ppm. During the transfer between the glove box and cryostat, the devices were consistently subjected to spin-coating with a layer of PMMA. Together with the  $\text{AlO}_x$  layer, it further prevents the air contamination

and sample degradation. Acetone, PMMA and isopropyl alcohol used in the fabrication process were all purified with molecular sieves.

### First-principles calculation

Density functional theory calculations were performed using Vienna Ab-initio Simulation Package (ref. 61) with the Perdew–Brue–Ernzerhof (PBE) exchange correlation functional<sup>62</sup>. The PBE +  $U$  method was used, using  $U = 4$  eV for the 3d orbitals of Mn (ref. 3). The plane-wave energy cutoff of 350 eV and the dense Monkhorst–Pack  $k$ -mesh of  $30 \times 30 \times 1$  were adopted for calculating the PMA energies. All calculations included the spin–orbit coupling and the DFT-D3 van der Waals corrections<sup>63</sup>.

### Transport measurements

Transport measurements were conducted in an Oxford dilution refrigerator with vector magnets providing a vertical field up to 9 T and a horizontal field up to 3 T. The excitation current was provided by a Keithley 6221 current source with an excitation of 10 nA at 4.56 Hz. Longitudinal resistance and Hall resistance were measured using standard lock-in technique by NF5650 and NF5645. The back-gate voltage was provided by a Keithley 2400 voltage source.

### Data availability

All raw and derived data used to support the findings of this work are available from the authors on request.

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**Author contributions** Yuyu Wang, C.L. and J.Z. supervised the research. Z.L., Yongchao Wang, Yongqian Wang, Yaoxin Li, Y.F., B.F. and S.Y. fabricated the devices and performed the transport measurements. Yongchao Wang, L.X. and Yuetan Li grew the  $\text{MnBi}_2\text{Te}_4$  crystals. Z.D. performed the TEM measurements. Z.L., M.M. and W.J. performed the simulation of the spin configurations. W.-H.D. and Y.X. performed the first-principles calculation. Z.L., C.L., J.Z. and Yuyu Wang prepared the paper with comments from all authors.

**Competing interests** The authors declare no competing interests.

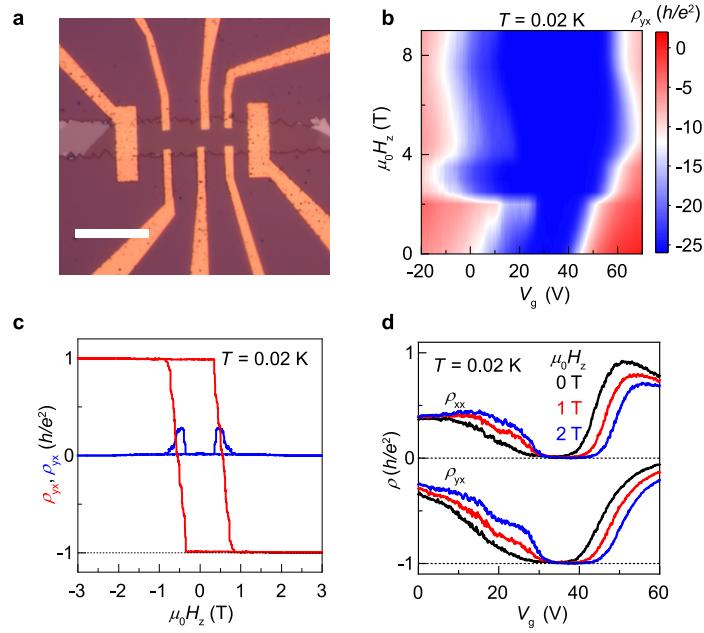
### Additional information

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**Correspondence and requests for materials** should be addressed to Chang Liu, Jinsong Zhang or Yuyu Wang.

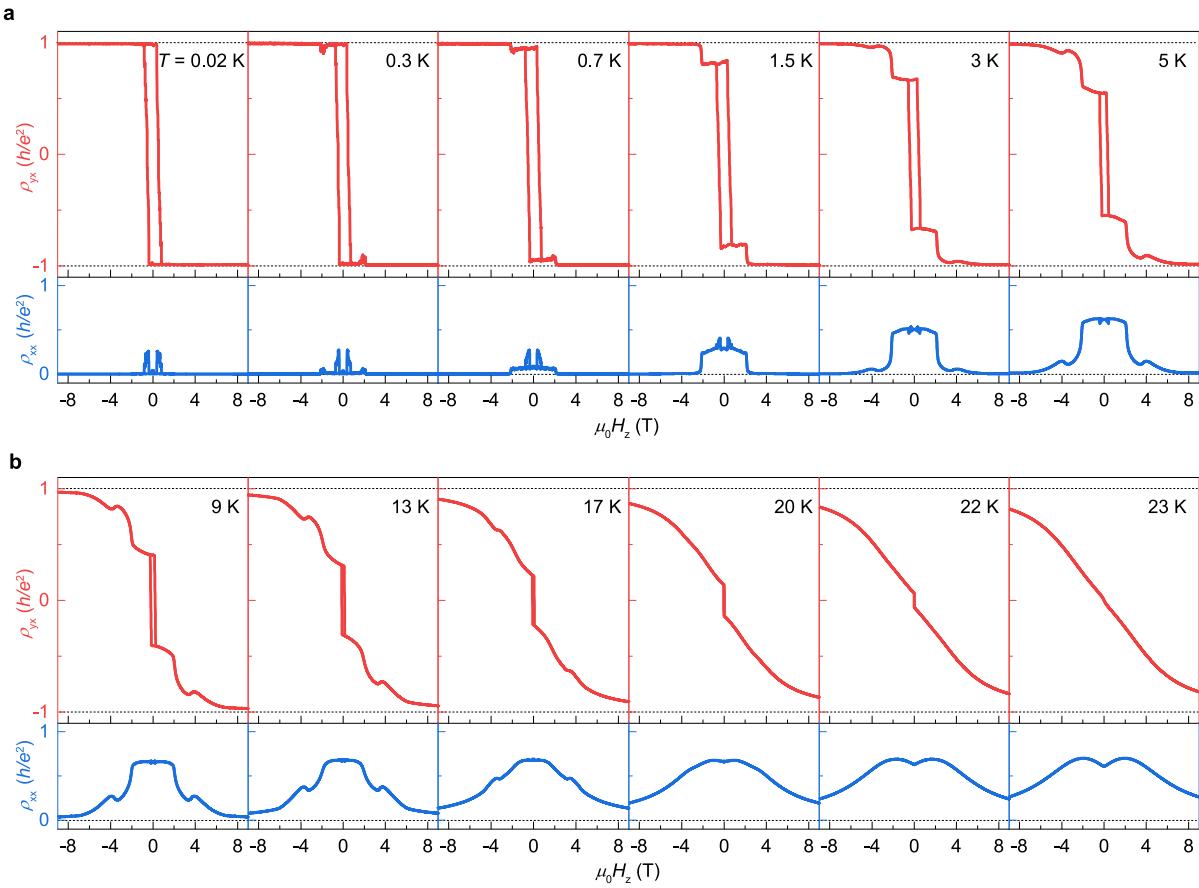
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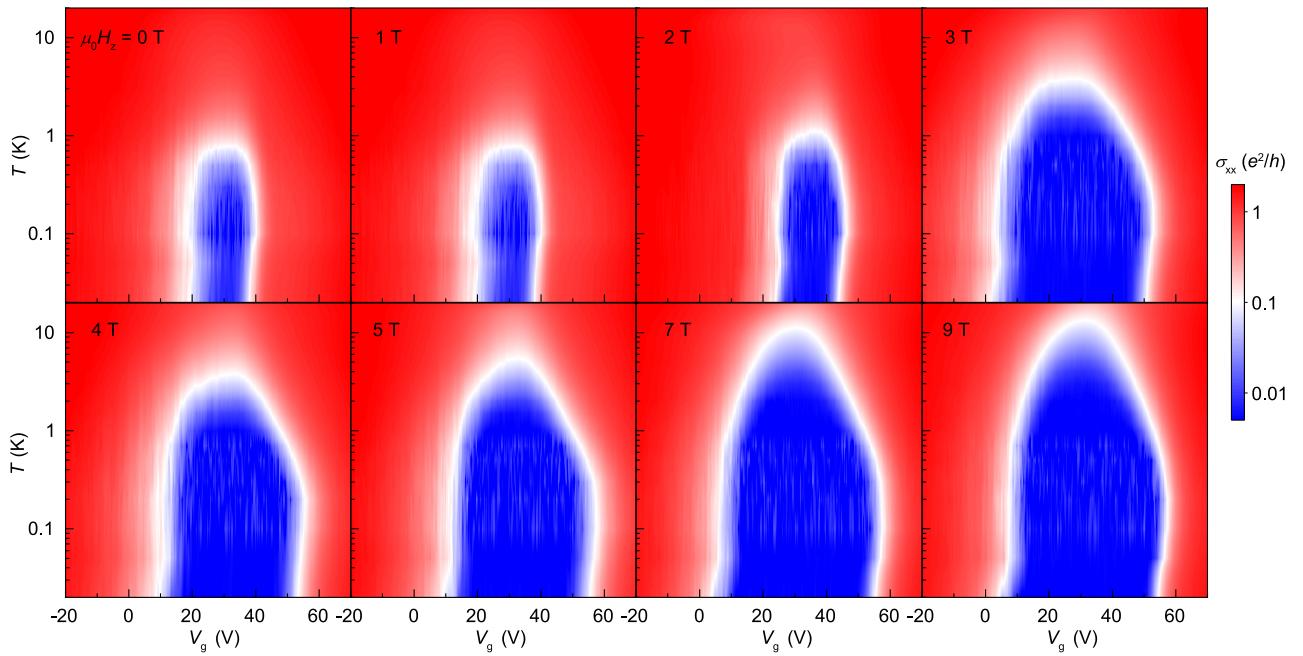


**Extended Data Fig. 1 | Transport data of the 7SL MnBi<sub>2</sub>Te<sub>4</sub> device at T=0.02 K.**  
**a**, Photograph of the measured device. The scale bar is 10  $\mu\text{m}$ . **b**, Colour map of  $\rho_{yx}$  as a function of  $H_z$  and  $V_g$  at  $T=0.02$  K. **c**, The  $\mu_0 H_z$  dependent  $\rho_{xx}$  (blue) and  $\rho_{yx}$  (red) curves at the CNP measured by using the Keithley 6221-2182 in the delta

mode with a current of 10 nA and a delay of 0.027 s, which demonstrates  $\rho_{xx}=0.012 \text{ } h/e^2$  and  $\rho_{yx}=0.988 \text{ } h/e^2$  at  $\mu_0 H_z=0$  T. **d**, The evolution of  $\rho_{xx}$  and  $\rho_{yx}$  as a function of  $V_g$  at  $\mu_0 H_z=0, 1$ , and  $2$  T.



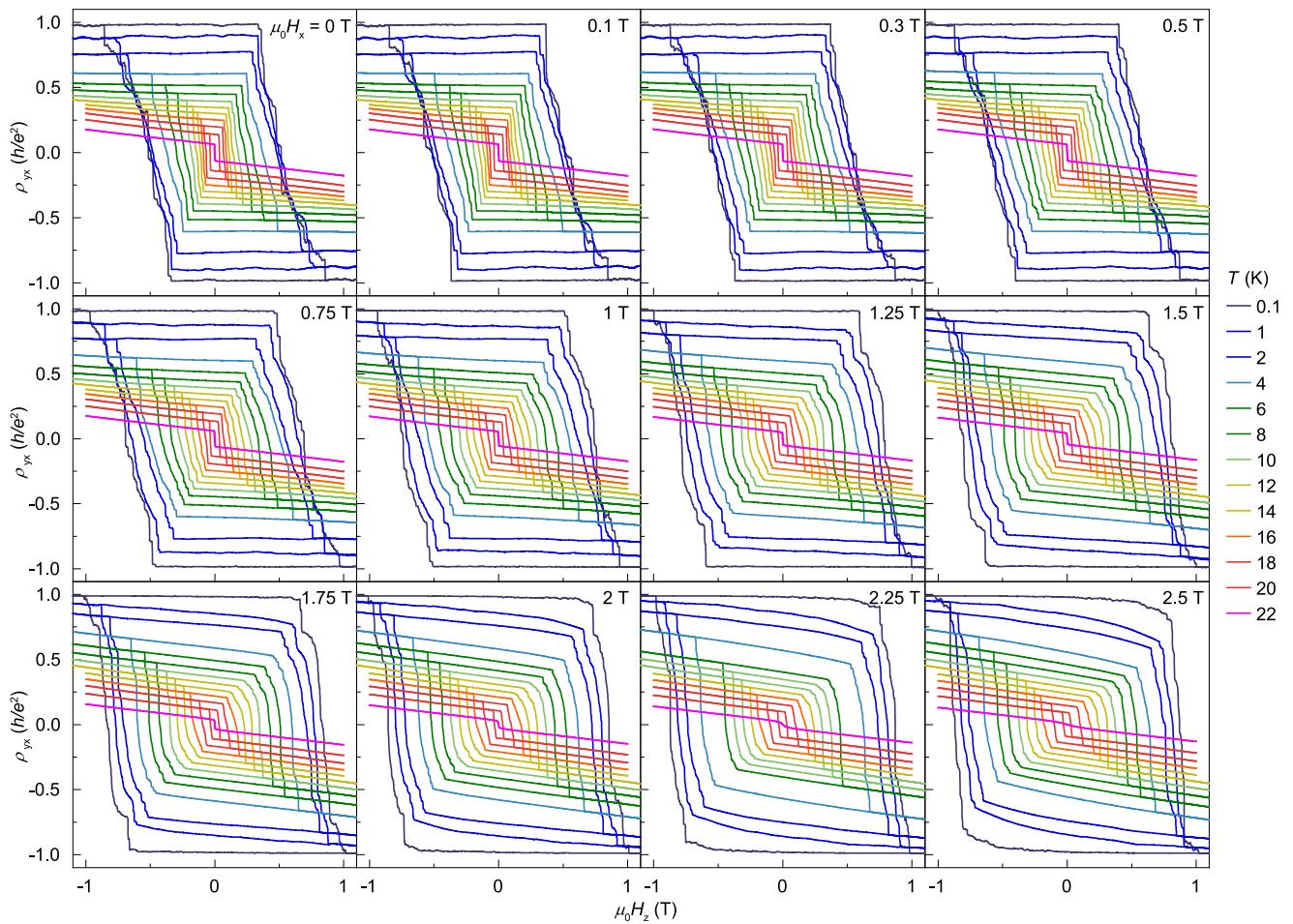
**Extended Data Fig. 2 | Individual  $H_z$ -dependent  $\rho_{xx}$  and  $\rho_{yx}$  curves for varied  $T$ s at  $V_g = 30$  V.** The upper and lower panels are the  $\rho_{yx}$  (red) and  $\rho_{xx}$  (blue) curves, respectively, from  $T = 0.02$  K to  $T = 23$  K. The one-step transition in the ground state is replaced by much more complex variations at higher  $T$ .



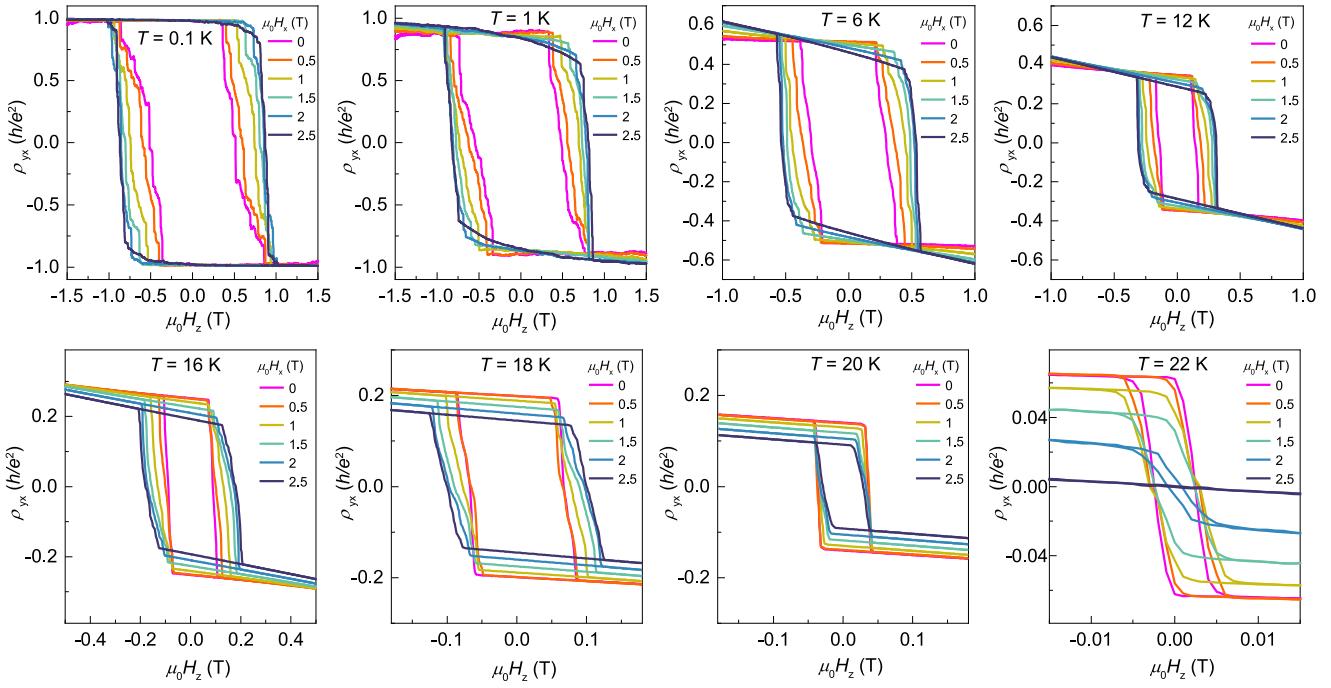
**Extended Data Fig. 3 | Colour map of  $\sigma_{xx}$  as a function of  $T$  and  $V_g$  at various  $\mu_0 H_z$ .** The  $V_g$  dependent transport data are measured at fixed  $\mu_0 H_z$  and selected  $T$ s ( $T = 0.02, 0.05, 0.1, 0.2, 0.3, 0.5, 0.7, 1, 1.5, 2, 3, 4, 5, 7, 9, 11, 13, 15, 17$  and  $20$  K).

The thermal activation gap size  $\Delta$  is extracted using the Arrhenius formula  $\ln \sigma_{xx} = -\Delta/2k_B T$ , where  $k_B$  represents the Boltzmann constant.

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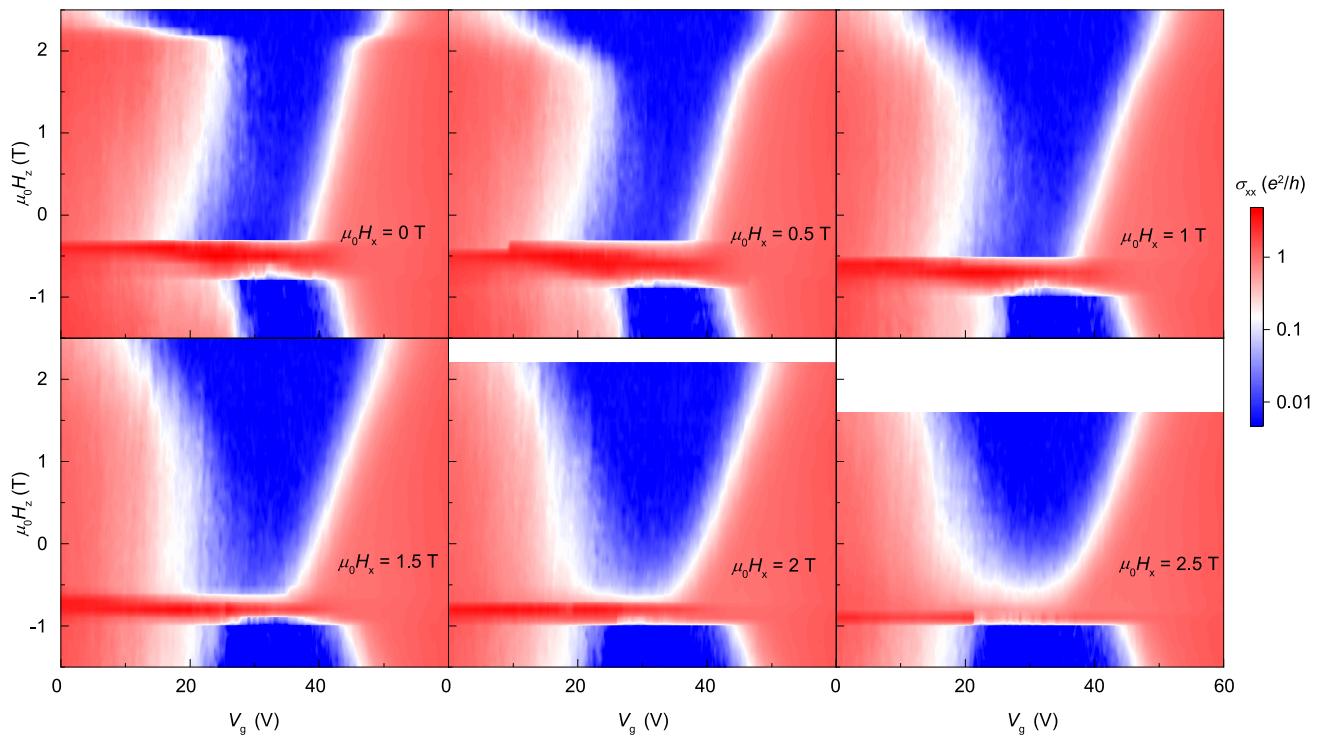


**Extended Data Fig. 4 | Complete data of  $\mu_0 H_z$  dependent  $\rho_{yx}$  at varied  $T$ s and  $\mu_0 H_x$ .** The measurements were conducted by sweeping  $H_z$  at different  $H_x$  at fixed  $T$ . The measuring sequence is from 0.01 K to 22 K. All data taken at  $V_g = 30 \text{ V}$ .



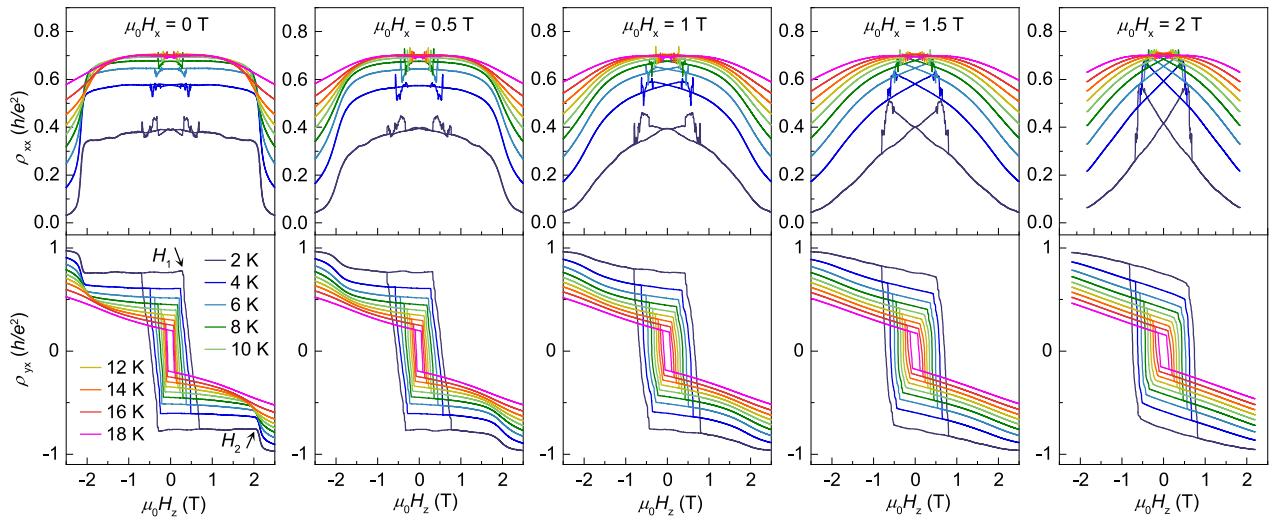
**Extended Data Fig. 5 | The hysteresis manipulated by in-plane magnetic field at different  $T$ s. a-f.** The  $\rho_{yx}$  versus  $H_z$  loops show that the coercivity increases with the application of  $H_x$  at  $T \leq 18$  K. **g-h.** Near the Néel temperature

( $T = 20$  and  $22$  K), the trend is reversed and the coercivity decreases with the application of  $H_x$ . All data taken at  $V_g = 30$  V.



**Extended Data Fig. 6 | Colour map of  $\sigma_{xx}$  in the parameter space of  $\mu_0 H_z$  and  $V_g$  at  $T=0.2 \text{ K}$  with increasing  $\mu_0 H_x$ .** The measurements were conducted by fixing  $\mu_0 H_x$  and sweeping  $V_g$  with  $\mu_0 H_z$  varied from  $+2.5 \text{ T}$  to  $-1.5 \text{ T}$ . As  $\mu_0 H_x$

increases, the QAH region indicated by blue colour is enlarged and the sudden gap increase at  $\mu_0 H_z \approx 2.2 \text{ T}$  becomes smoother. When  $\mu_0 H_x$  is increased to  $2 \text{ T}$ , the AFM to SSF transition nearly disappears.



**Extended Data Fig. 7 | The  $\mu_0 H_z$  dependence of  $\rho_{xx}$  and  $\rho_{yx}$  at varied  $\mu_0 H_x$ .** The application of  $H_x$  smears out the transition at  $H_2$  in both  $\rho_{xx}$  (upper panel) and  $\rho_{yx}$  (lower panel). Meanwhile, the hysteresis is increased, accompanied by a sharper transition at  $H_1$ . All data taken at  $V_g = 30$  V.